

INFORMATION DISCLOSURE STATEMENT BY APPLICANT

(use as many sheets as necessary)

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Complete if Known

Application Number 10/604,740

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First Named Inventor W. R. STOWELL et al.

Art Unit 2879 1746

Examiner Name CARLILLO

Attorney Docket Number 124251

U.S. PATENT DOCUMENTS

Examiner Initials*	Cite No. ¹	Document Number		Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear
		Number	Kind Code ² (if known)			
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		US- 4,098,450		07/04/1978	Keller et al.	
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		Office ³	Number ⁴	Kind Code ⁵ (if known)				

OTHER PRIOR ART - NON PATENT LITERATURE DOCUMENTS

Examiner Initials*	Cite No. ¹	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s) volume-issue number(s), publisher, city and/or country where published.	T ²
b6		BRECELJ, F. et al., "Reduction of metal oxide thin layers by hydrogen plasma", Vacuum, 1990, pgs. 177-178, Vol. 40, Numbers 1/2, Pergamon Press plc (1990).	
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Examiner Signature

S. Cell

Date Considered

3/11/05